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PATENT

Docket No.: 050432-0616

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Seung-Hyun RHEE
Appl. No. : 10/728,772
Filed : December 8, 2003
Title : A METHOD OF FORMING AN
INTERLEVEL DIELECTRIC LAYER
EMPLOYING DIELECTRIC ETCH-BACK
PROCESS WITHOUT EXTRA MASK SET

Customer No.: 41552
Confirmation No.: 1077

CERTIFICATE OF FACSIMILE TRANSMISSION

I hereby certify that this correspondence is being facsimile transmitted to
the Patent and Trademark Office on April 4, 2006.

Brenda Lewis

Grp./A.U. : 1765
Examiner: : Mahmoud Dahmane

REQUEST FOR RECONSIDERATION UNDER CFR 1.116

Mail Stop A1F
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Request for Reconsideration is respectfully submitted in response to the Final Office

Action dated January 4, 2006.

A listing of the Claims begin on page 2 of this paper.

Remarks begin on page 5 of this paper.

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